Two-dimensional Cu(I)-MOF with mesoporous architecture towards chemiresistive NO₂ sensing

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General Information

1.1 Reagents

Materials required for the synthesis of DPA were purchased from Avra Chemicals. For ligand synthesis, TLC was used to monitor reaction progress using a Merck 60 F254 precoated silica gel plate (0.25 mm thickness), and the products were judged in a UV chamber. Both ¹H and ¹³C {¹H} NMR spectra were collected using a Bruker 500 MHz spectrometer in DMSO-d⁶. Data for proton NMR chemical shifts are shown in ppm downfield from tetramethyl silane and are mentioned in delta (δ) units. The ¹H NMR splitting patterns are singlet (s), doublet (d), triplet (t), and multiplet (m), and Mestre Nova processed the NMR data. Unless otherwise specified, chemicals were used exactly as received. CuI (>99%) from Loba Chemie Pvt. Ltd., and used without further purification. Solvents like diphenyl ether, acetonitrile (HPLC grade) were bought from Advent Chembio Pvt. Ltd.

Instruments

Powder X-ray diffraction (PXRD) data were recorded on Rigaku Smart X-ray diffractometer with monochromatic Cu K α (0.1540 nm) radiation in 2 θ range of 5-50 degrees. The attenuated total reflectance infrared spectroscopy (ATR-IR) was performed on Bruker Alpha II spectrophotometer of the powdered sample in the range of 4000-400 cm⁻¹. We have used a field

emission scanning electron microscope (FE-SEM) on JEOL JSM-7400F for morphological characterization and its elemental mapping. The thermogravimetric analysis was performed on Mettler Toledo TGA 1-star e-system in the temperature range of 30-700 °C.

Crystallographic details

Single crystal X-ray diffraction studies for **Cu-MOF** were carried out using Agilent technology (Oxford diffraction) super Nova CCD system, with monochromated Mo K α radiation (λ =0.71073 Å). Unit cell determination, data collection and reduction, and empirical absorption correction were performed using the CrysAlisPro program. Using Olex2¹, the structure was solved with the SHELXT² structure solution program using Intrinsic phasing and refined with the SHELXL refinement package using Least Squares minimisation.

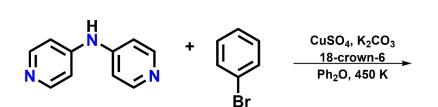
Sensing Measurements

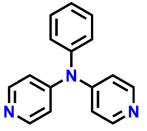
5N purity gases such as (NO₂, NH₃, H₂S, SO₂, and CO₂) are employed to measure the sensing performance of the fabricated sensor. The flow rate of these gases is precisely controlled by using an advanced mass flow controller (model: Alicat, MC11 slpm, USA). The concentration of these test gases is varied by mixing the synthetic air (99.999 Purity) into the mixing chamber before exposing it on the sensor surface. The resistance change of the sensing layer during test gas exposure is continuously monitored on the Keithley-2612A source meter by applying a constant voltage of +1 V.

2.1 Synthesis of *N-phenyl-N-(pyridine-4-yl)pyridine-4-amine* (PDPA)

4,4'-Dipyridylamine (DPA) was synthesized following a previous report by Bureš *et al.*³ For the synthesis of PDPA, in a two-neck r.b., DPA (2000 mg, 11.7 mmol) was added with CuSO₄(360 mg, 2.2 mmol), 18-crown-6 (120 mg, 0.05 mmol), potassium carbonate (3200mg, 23.4 mmol) with bromobenzene (3.6 mL, 34.8 mmol) in diphenyl ether (15 mL). The reaction temperature was maintained at 450K for two days in N₂. 2 days later, 200 mL of DCM and 200 mL of MeOH were added to the reaction mixture and passed through the celite pad. Most of the solvent was dried except diphenyl ether. Solvent and other impurities were removed and the compound was purified by column chromatography (Ph₂O and bromobenzene were removed by hexane as eluent and PDPA was obtained in ethyl acetate as eluent). (Yield:2000 mg, ~70%). ¹H NMR (500 MHz, DMSO-d₆) δ 8.41 (s, 4H), 7.50 (t, *J* = 7.7 Hz, 2H), 7.37 (t, *J* = 7.6 Hz, 1H), 7.23 (d, *J* = 8.1 Hz, 2H), 6.95 (d, *J* = 4.7 Hz, 4H). ¹³C{¹H} NMR (126 MHz, 2H)

DMSO-d₆) δ 150.99, 150.16, 143.03, 129.92, 127.17, 126.52, 115.52. LCMS (ESI) *m/z* calculated for C₁₆H₁₃N₃ [M+H]⁺ 248.1182, found 248.1201.





Scheme S1. Synthesis of PDPA

2.2 ATR-IR of PDPA

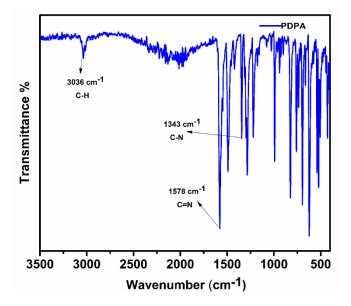
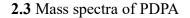


Figure S1. IR spectra of PDPA



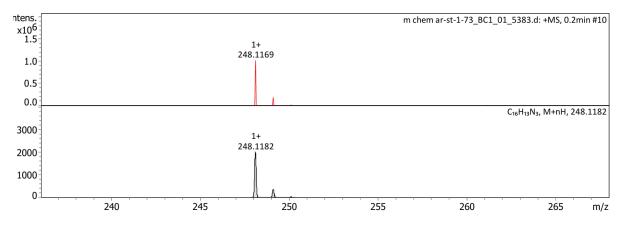


Figure S2. Mass spectra of PDPA

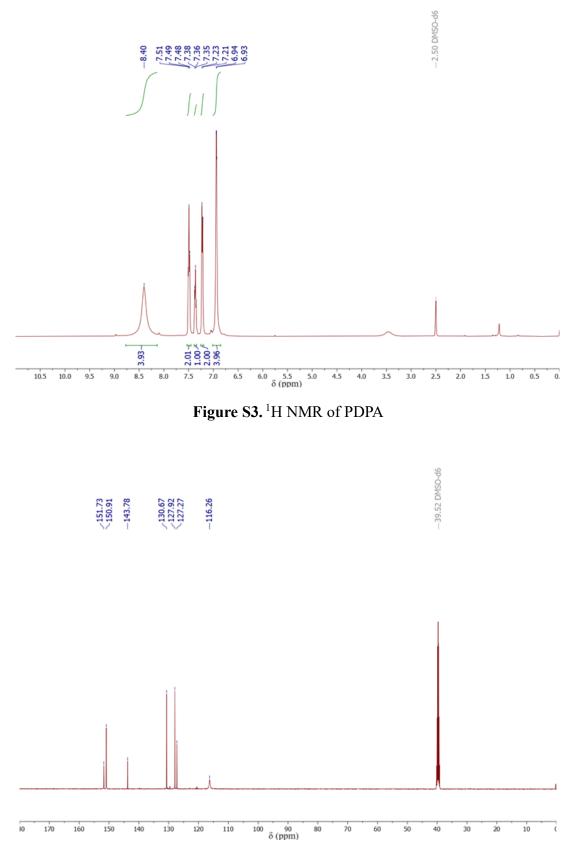
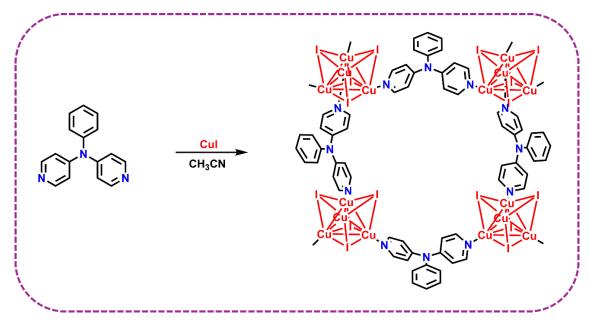


Figure S4. ${}^{13}C{}^{1}H$ NMR of PDPA

2.5 Synthesis of Cu-MOF

Into a 50 mL Schenk tube under N₂ condition, PDPA (100 mg, 0.8 mmol) was dissolved in 2mL DCM, to which CuI (153 mg, 1.6 mmol) dissolved in 10 mL ACN was added and resulted in instant white precipitates. The reaction mixture was stirred for 12 hours, after which the compound was dried and washed with ACN. (Yield: 200 mg, \sim 80%). Crystals were obtained by slow diffusion of CuI dissolved in ACN over ligand dissolved in DCM.



Scheme S2. Synthesis of Cu-MOF

2.6 ATR-IR of Cu-MOF

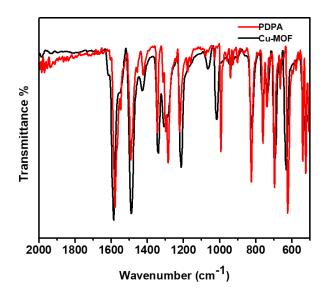


Figure S5. Comparison of IR spectra of PDPA and Cu-MOF

3.1 Structure of Cu-MOF

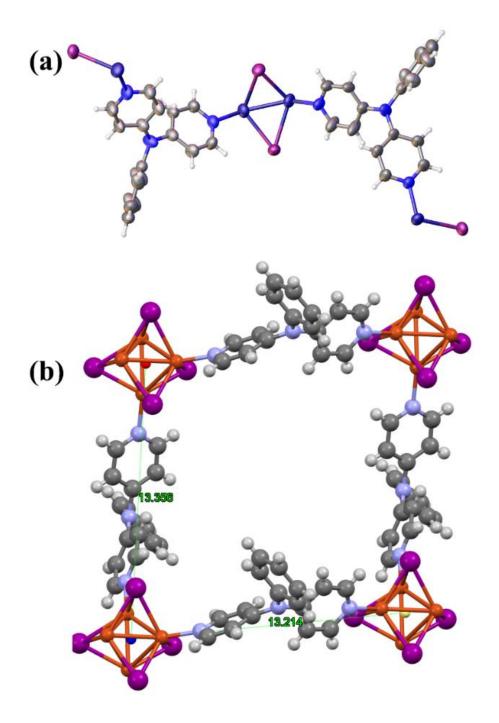


Figure S6. (a) The asymmetric unit of Cu-MOF (b) different lengths across axes

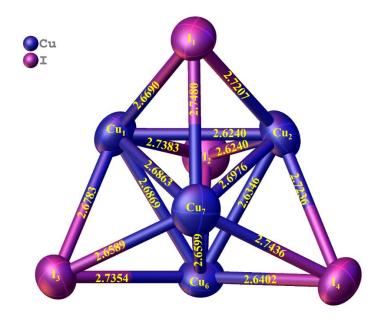


Figure S7. Bond lengths of Cu-Cu and Cu-N in Cu₄I₄ SBU

3.2 PXRD and TGA of Cu-MOF

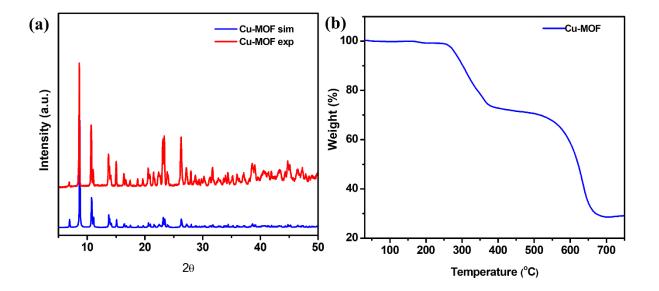


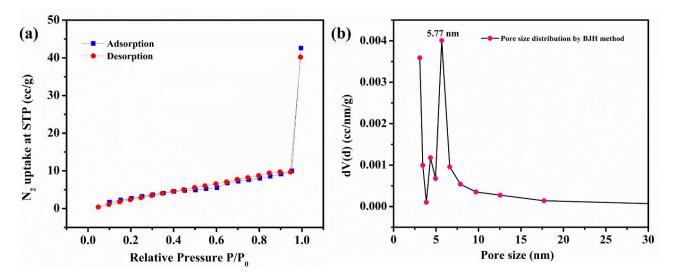
Figure S8. (a) PXRD patterns of Simulated and experimental Cu-MOF (b) TGA curve of Cu-MOF

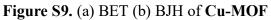
3.3 Crystallographic parameters of Cu-MOF

 Table S1. Crystallographic table

Compound	Cu-MOF
CCDC No.	2385865
Formula	$C_{35}H_{31}Cl_2Cu_4I_4N_7$
Formula Weight	1382.33
Wavelength	0.71073 Å
Crystal System	monoclinic
Space group	Сс
a/Å	16.9593(2)
b/ Å	20.2694(2)
c/ Å	13.3565(2)
α /°	90
β/°	105.5110(10)
γ/°	90
V/ Å ³	4424.14(10)
Z	4
<i>P</i> _{calcd} (g/cm ³)	2.075
Temperature/K	298.00
GOF	1.034
2θ range for data collection	4.006 to 54.814
Reflections collected	70029
Independent	9468 [R _{int} = 0.0377,
reflections	$R_{sigma} = 0.0283$]
Completeness to	99.8
θ=25.242	
Final R indices	$R_1 = 0.0345, wR_2 =$
[I>2σ(I)]	0.0766
Final R indices	$R_1 = 0.0416, wR_2 =$
[all data]	0.0801
Largest diff.	0.48/-0.52
peak/hole/ e Å ⁻³	

3.4 Surface analysis of Cu-MOF





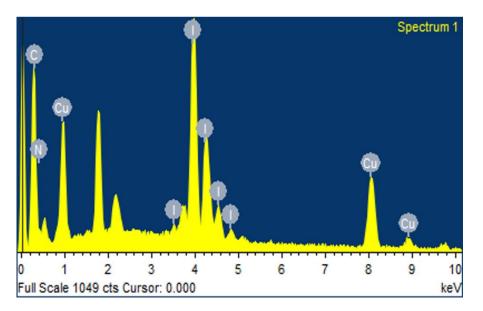


Figure S10. Energy Dispersive X-ray of Cu-MOF

3.5 Semiconducting Behaviour of Cu-MOF

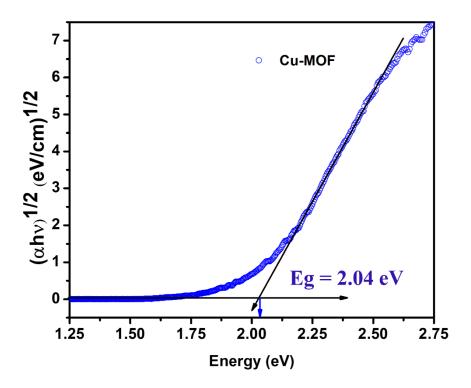


Figure S11. Tauc-Plot of Cu-MOF

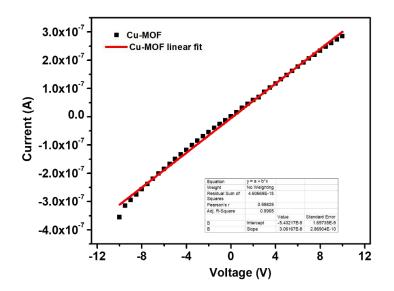


Figure S12. Electrical Conductivity of Cu-MOF

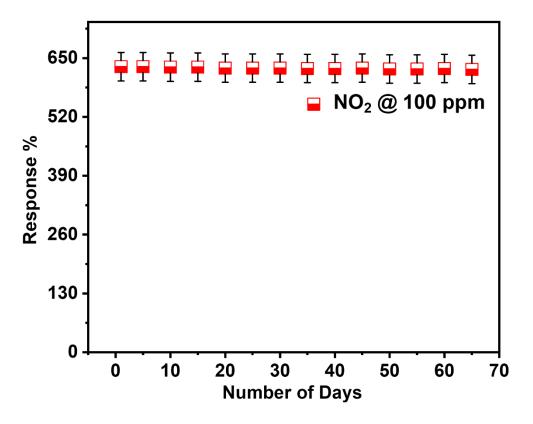


Figure S13. Long-term stability of Cu-MOF-based gas sensor

4.1 Gas sensing behavior of Cu-MOF

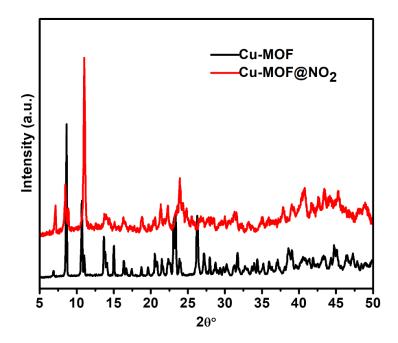


Figure S14. Comparison of PXRD patterns of Cu-MOF before and after exposure to NO2

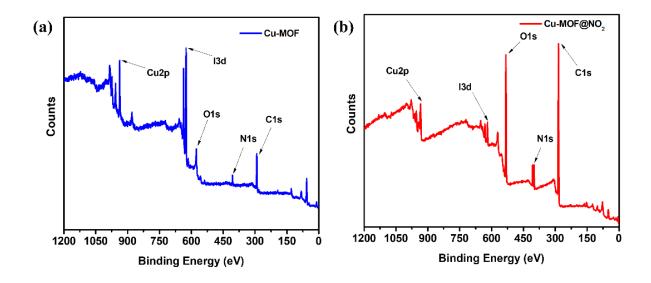


Figure S15. (a) XPS survey of Cu-MOF (b) XPS survey of Cu-MOF after NO₂ exposure.

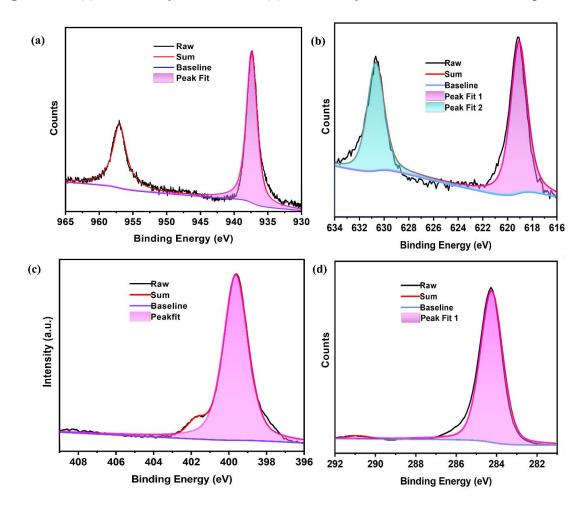


Figure S16. High-resolution XPS spectra of Cu-MOF (a) Cu2p (b) I3d (c) N1s (d) C1s

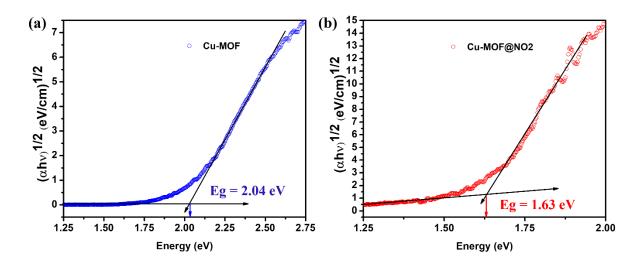


Figure S17. Tauc-Plot of Cu-MOF (a) before exposure to NO_2 (b) after exposure to NO_2

4.2 Comparison of Cu-MOF as a gas sensor

Table S2. Comparison table for NO2 gas sensing with MOF-based sensor at room temperature.

Serial No.	Sensing material	Conc. (ppm)	Response /Recovery time (s)	LOD #	References
1.	Cu-Salphen- MOF	10	135/412.2	0.28 ppm	Angew. Chem. Int. Ed., 2023, 62 , e202302645
2.	Cu ₃ (HHTP) ₂	1	1080/		Adv. Sci., 2019, 6 , 1900250
3.	HIOTP-Ni	10	101.4/619.2	0.21 ppm	Angew. Chem., 2023, 1 35 , e202306224
4.	Zn ₃ (HHTQ) ₂	3	132/594	0.269 ppm	Angew. Chem. Int. Ed., 2024, 35 , e202408189
5.	CuI-K-INA	10	121.8/312.6	14.12 ppb	J. Am. Chem. Soc., 2023, 145 , 19293– 19302
6.	Cu ₃ (HHTP) ₂ powder	3	1038/	1 ppm	<i>Nat. Commun.</i> , 2021, 12 , 4294
7.	PCN-222-Cu	0.02	67/261	0.93 ppb	ACS Sens., 2023, 8 , 4353–4363
8.	PCN-222-Ni	0.15	82/159	5.98 ppb	ACS Sens., 2023, 8 , 4353–4363
9.	Cu(I) CP	10	15.5/21	1.3 ppb	Small, 2025, 2409553
10.	Cu-MOF	10	11.6/13	3.5 ppb	This Work

Seria l No.	Sensing material	Conc. (ppm)	Response /Recovery time (s)	LOD [#]	References
1.	Ni3(HHTP)2/ polyimide (PI), tape (PET)	0.2	/30	56 ppb	ACS Sens., 2024, 9 , 1916–1926
2.	Au/ZIF-8-film	10	7.2/>600	0.19 ppm	ACS Appl. Mater. Interfaces, 2019, 11 , 13624–13631
3.	Cu ₃ (HHTP) ₂ -NFs	5	~ 600/~ 600		ACS Cent. Sci., 2021, 7, 1176–1182
4.	Cu ₃ (HHTP) ₂ /Fe ₂ O 3	5	~ 600/~ 600	11 ppb	ACS Cent. Sci., 2021, 7, 1176–1182
5.	Cu ₃ (HHTP) ₂ Thin film	3	840/	1 ppm	Nat. Commun., 2021, 12 , 4294
6.	MIL-101(Cr)⊃ PEDOT	10	150/Irr.	0.06 ppm	J. Am. Chem. Soc. <i>138</i> , 10088–10091
7.	LIG@Cu ₃ (HHTP ₂)	0.01	16/15	0.168 ppb	<i>Nat. Commun.</i> , 2023, 14 , 3114
8.	Pd@Cu ₃ (HHTP) ₂	5	828/	1ppm	Adv. Sci., 2019, 6 , 1900250
9.	Thin film Pt@Cu ₃ (HHTP) ₂	3	492/	0.1 ppm	Nat. Commun., 2021, 12 , 4294
10.	Cu-MOF	10	11.6/13	3.5 ppb	This Work

Table S3. Comparison table for NO2 gas sensing with hybrid MOF-based sensor at room temperature.

#:- LOD values are determined by $(3*SD/\sigma)$ where, SD represents the deviation of sensor response values obtained in the presence of air, while σ represents the slope of the linear portion of the calibrated curve.

4.3 Theoretical calculations of Cu-MOF

	Atom	Before adsorption	After Adsorption
	Cu1	18.744	18.582
	Cu2	18.750	18.682
Cu-MOF	Cu3	18.739	18.694
Cu-MOI	Cu4	18.750	18.758
	I1	7.317	7.280
	I2	7.338	7.332
	I3	7.336	7.291
	I4	7.310	7.283
	N	4.897	5.002
Adsorbate NO ₂ molecule	0	6.050	6.231
	0	6.053	6.225

Table S4. The calculated Mulliken charges (in e) before and after adsorption onNO2molecule and Cu-I complex of Cu-MOF

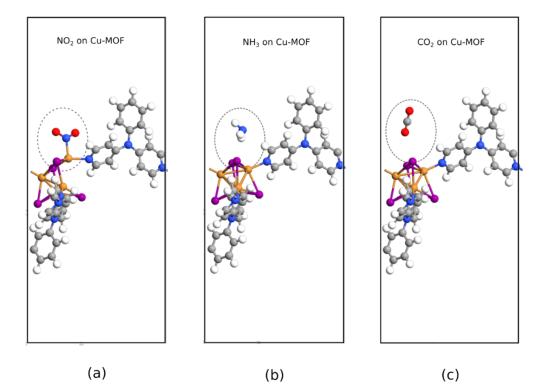


Figure S18. Interaction of Cu-MOF with (a) NO₂ (b) NH₃ (c) CO₂

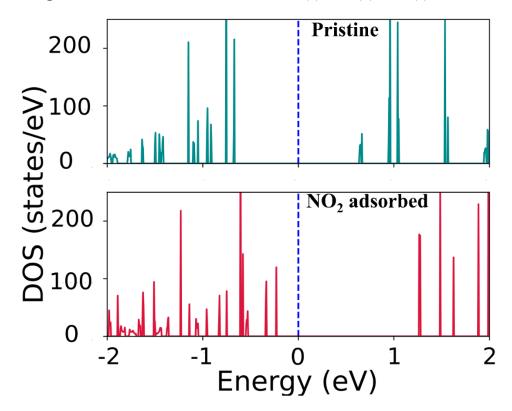


Figure S19. DOS of prinstine and adsorbed NO2 on Cu-MOF

References:

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- 6B. Le Ouay, M. Boudot, T. Kitao, T. Yanagida, S. Kitagawa and T. Uemura, J. Am. Chem. Soc., 2016, **138**, 10088–10091.